

Date: March 1, 2004

Inventor(s): Richard S. Belliveau

Title: CONTENT OPTIMIZING SYSTEM FOR AN IMAGE
PROJECTION LIGHTING DEVICES

Date Filed:

Serial No:

INFORMATION DISCLOSURE STATEMENT

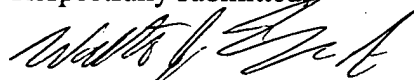
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir or Madam:

Applicant submits this statement in accordance with the duty of disclosure under 37 C.F.R. 1.56 and 1.97-1.98. This statement is filed in accordance with 37 C.F.R. 1.97(b)(1), within three months of the filing date of a national application.

The English language references are listed on attached Form PTO-1449 and require no further commentary under 37 C.F.R. 1.98(a)(3). Applicant respectfully solicits the Examiner's consideration of the cited references and entry thereof into the record of this application.

Respectfully submitted



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Section 2. Form PTO - 1449 (Modified)

FORM PTO-1449 U.S. Department of Commerce (Modified) PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary) (37 CFR 1.98(b))	ATTY. DOCKET NO.: Belliveau - 22	SERIAL NO.:
	APPLICANT(S): Richard S. Belliveau	
	FILING DATE:	GROUP

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUB- CLASS	FILING DATE IF APPROPRIA TE
		6	0	5	7	9	5	8	5/2/00	Hunt			
		5	8	2	9	8	6	8	11/3/98	Hutton			

FOREIGN PATENT OR PUBLISHED FOREIGN PATENT APPLICATION

		DOCUMENT NUMBER							PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION YES NO	

OTHER DOCUMENTS (Including Author, Title, Date, Relevant Pages, Places of Publication^{***})

			* The High End System Product Line 2001*
			High end System, Inc., Austin Texas
			* Catalyst DL 2000 *© 2003, High End System Inc.

EXAMINER	DATE CONSIDERED
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EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.